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Real-time molecular-level visualization of mass flow during patterned photopolymerization of liquid-crystalline monomers

Keisuke Ueda¹, Miho Aizawa^{2,3}, Atsushi Shishido¹ and Martin Vacha¹

Abstract

Single-particle fluorescence imaging is used to monitor dynamic processes that occur during patterned photopolymerization of liquid-crystalline monomers. A spatial gradient of chemical potential can be created at the border of bright and dark regions by structured illumination in the photopolymerization process, leading to mutual diffusion of polymers and monomers. Analysis of the fluorescence from single quantum dots doped into the monomers at minute concentrations enables visualization of highly directional flow from the illuminated region where the photopolymerization proceeds toward a masked unpolymerized region. This directional mass flow causes flow-induced orientation of the polymers that is subsequently fixed by completion of the polymerization reaction, resulting in a mesoscopic aligned area of the polymer film.

Introduction

The preparation of molecularly aligned structures not only is a fascinating topic from the standpoint of basic molecular physics but also has tremendous technological significance for next-generation optoelectronic, photonic, mechanical, or biomedical materials and devices^{1–4}. Traditionally, polymers have been oriented by mechanical processes such as stretching or flow processes such as extrusion. As more advanced methods, photoalignment processes have been developed that enable orientation of side-chain liquid-crystalline (LC) polymers, surface-grafted polymers, or block copolymers^{5,6}. In particular, side-chain LC polymers offer a variety of alignment methods that take advantage of the technology developed for LC molecules by combining with photopolymerization techniques. A disadvantage of methods that involve the

addition of dyes required for photoisomerization, photocrosslinking, or photodecomposition is the inevitable dye residue that degrades the optical properties of the resulting polymer films. On the other hand, methods that allow for alignment without additives, such as the use of photoalignment layers or surface topography templates, have some difficulties in terms of technological complexity and time requirements because these methods involve multistep processes^{7–10}.

Recently, a novel and efficient alignment method that does not require the use of additives has been proposed and demonstrated. The method uses spatially patterned unpolarized light to initiate photopolymerization and achieve molecular alignment in an area of a sample where a chemical potential gradient has been created by the presence of polymerized and unpolymerized regions^{11–14}. The gradient is assumed to result in mass flow that aligns the precursor monomers and polymers. Continued irradiation further promotes the polymerization and fixes the molecular motion of polymers in the aligned state. The concentration gradient and the following molecular alignment are restricted to a narrow area near the edge of bright and dark regions of the photomask. However, by

Correspondence: Atsushi Shishido (ashishid@res.titech.ac.jp) or Martin Vacha (vacha.m.aa@m.titech.ac.jp)

¹Department of Materials Science and Engineering, Tokyo Institute of Technology, Ookayama 2-12-1-58-44, Meguro-ku, Tokyo 152-8552, Japan

²Laboratory for Chemistry and Life Science, Institute of Innovative Research, Tokyo Institute of Technology, R1-12, 4259 Nagatsuta, Midori-ku, Yokohama 226-8503, Japan

Full list of author information is available at the end of the article

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scanning such illumination stripes or spots over the sample, it is possible to prepare well-aligned large-scale or patterned LC polymer films^{12–14}.

In this work, we aim to provide unambiguous evidence of the phenomenon of mass flow during photopolymerization and its role in the alignment mechanism and to further distinguish between monomer and polymer diffusion. For this purpose, we directly visualize the mass flow occurring near a photomask in real time during the photopolymerization reaction by single-molecule fluorescence imaging^{15–18}. The precursor monomer LC film is doped with a very low concentration of highly luminescent quantum dots (QDs), and we use an inverted fluorescence microscope to track the positions of individual QDs. The sample on top of the microscope stage is heated up to 100 °C by Joule heating using a thin layer of indium thin oxide (ITO) deposited on microscope cover glass^{19,20}. The photopolymerization is carried out in situ on the microscope stage by UV laser illumination.

Materials and methods

Sample preparation

The mesogenic monomer 4-[(6-acryloyloxy)hexyloxy]-4'-cyanobiphenyl, abbreviated A6CB, was dissolved in spectral grade toluene and mixed with a small amount of dilute toluene solution of CdSe/ZnS quantum dots (Lumidot 640, Sigma-Aldrich). The average size of the quantum dots is 6.3 nm (8.6 nm including ligands), and they are stabilized with hexadecylamine (HDA) and trioctylphosphine (TOPO) ligands. The QDs were chosen for their fluorescence in the red part of the visible spectrum (Fig. S1a), which enabled a significant reduction in the background signal from the bulk of the sample. The mixture was vacuum-oven dried for 2 h, and a small amount of the solid sample was placed on top of a microscope cover glass (22 mm × 22 mm × 0.15 mm) coated with a thin ITO layer. The ITO had been etched to form a stripe 5 mm in width with a resistance of 0.5 kΩ. The sample was then heated on a hot plate to above 80 °C, and after melting, it was covered with a smaller piece (3 mm × 6 mm) of cover glass with a thin layer of Al as a photomask evaporated on half of its area.

Microscope setup for single-particle tracking and real-time photopolymerization

Single-particle experiments were performed using an inverted fluorescence microscope (Olympus IX 71) with an oil immersion objective lens (Olympus, UPlan FLN 100×/1.3 Oil) or an air objective lens (Olympus, PlanFLN 100×/0.95). The samples were excited with the 488 nm line of an Ar ion laser (Coherent Innova 70), and the fluorescence was detected using an electron-multiplying (EM) CCD camera (iXon, Andor Technology) after passing through appropriate optical filters.

The typical acquisition time of the CCD was 100 ms with 300 gain.

The sample was heated by running a current through the ITO stripe, and its temperature was measured using an infrared thermometer. Typical current–temperature curves for the oil and air objective lenses are shown in Fig. S2. The sample can be heated to 100 °C, and we verified by imaging control samples of polystyrene dispersed QDs that sharp single-particle images can be obtained even at the temperatures used in this experiment (80 °C), as shown in Fig. S1b, c.

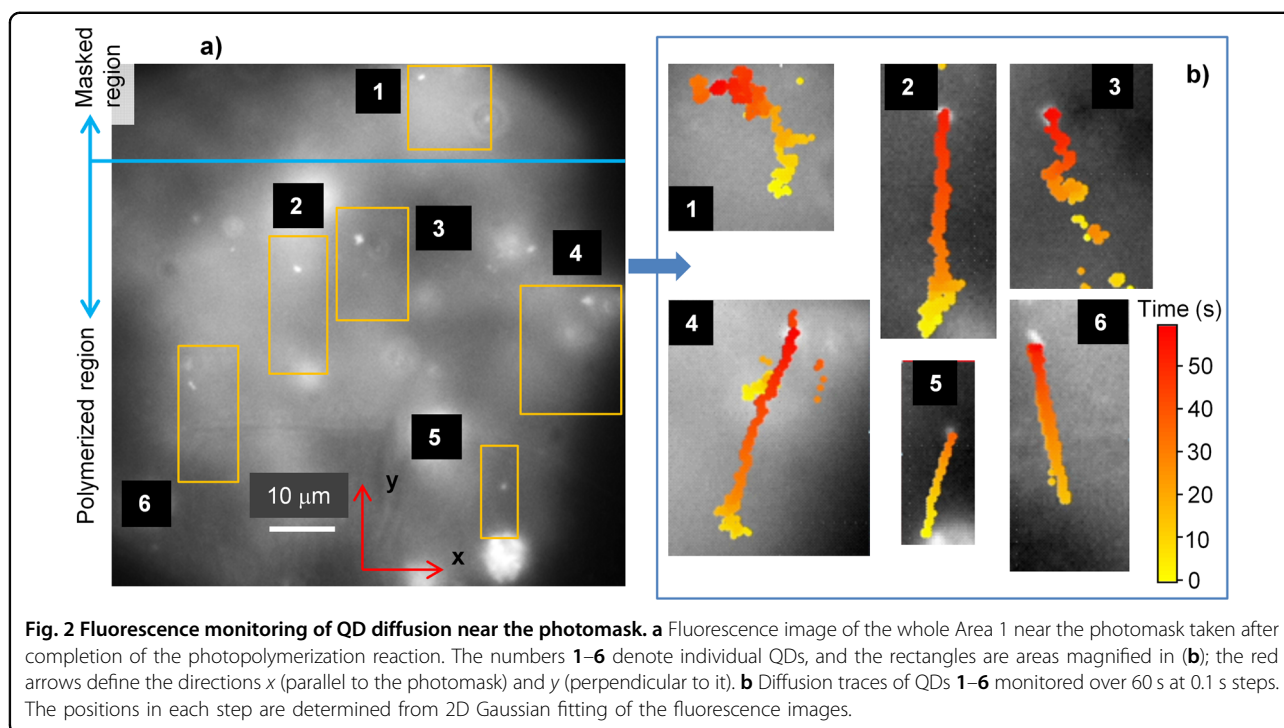
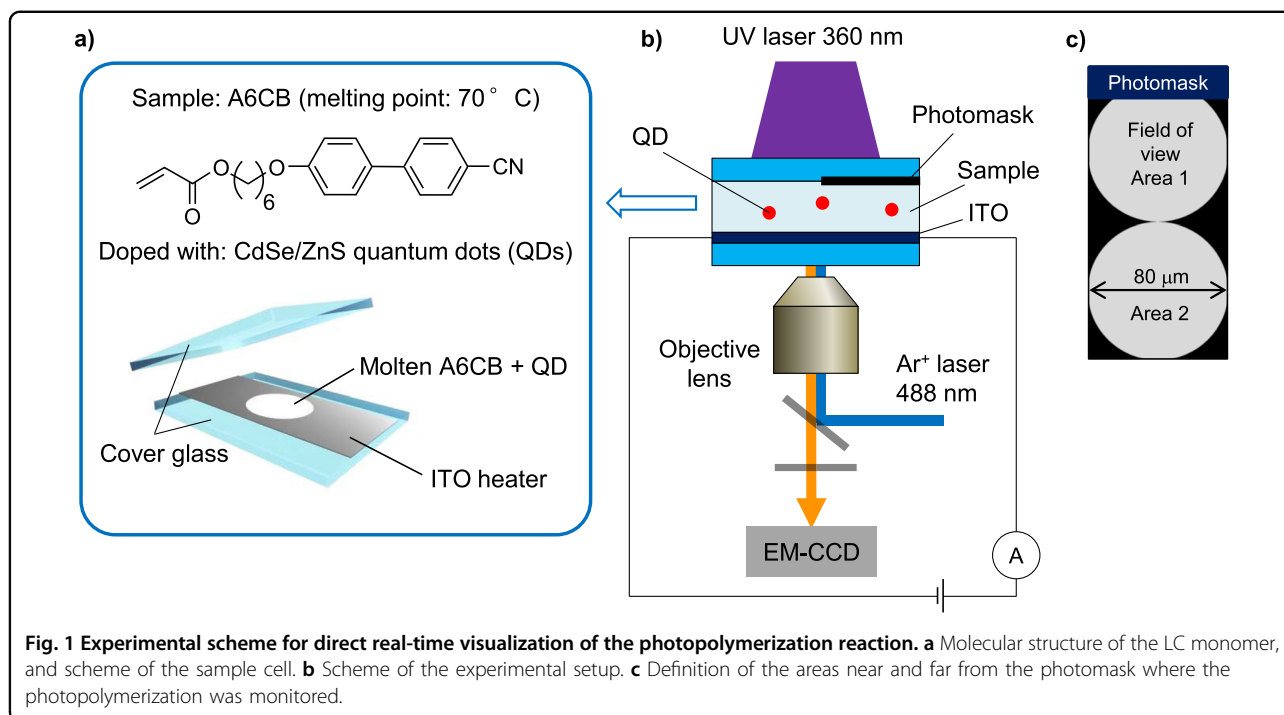
Photopolymerization was carried out using a 360 nm UV laser (UV-FN-360-100mW, CNI), which was expanded five times by a beam expander and reflected by a set of mirrors on top of the microscope stage. The irradiation spot had a diameter of 3 mm, and the typical laser power for the polymerization reaction was 1.5 mW cm⁻².

Polarization microscopy experiments were performed in transmission mode on the same microscope using a halogen lamp, a pair of polarizers, and additional filters. The whole microscope setup is shown in Fig. S3.

Results and discussion

The experimental scheme for direct visualization of the photopolymerization is shown in Fig. 1. The monomer (A6CB) doped with red-emitting CdSe/ZnS core/shell QDs was prepared by dissolving both components in toluene and mixing them at appropriate concentrations. The mixture was then dried in a vacuum oven, and the powder was deposited on an ITO-covered microscope cover glass and heated on a hot stage above the melting point (to 80 °C). After melting, the sample was covered with another microscope cover glass onto which a thin Al layer had been evaporated as a photomask. This sandwich structure (of an ~5 μm thickness) was then cooled down and placed on top of the microscope stage, and the ITO was electrically connected to a power supply. In the photopolymerization experiment, the sample was first heated by the ITO above the melting point and kept in the molten state. The molten state was verified by a transmission microscope image and consequently by monitoring free Brownian diffusion of the QDs in epi-fluorescence mode. Irradiation of the sample with UV light (360 nm, 1.5 mW/cm²) for several minutes caused the photopolymerization to proceed, and completion of the reaction was confirmed by immobilization of the diffusing QDs, as well as by a change in the transmission image.

To examine the effect of the photomask on molecular alignment during photopolymerization, we carried out real-time monitoring of the reaction under continuous UV irradiation at two different locations, as shown in Fig. 1c. The locations were determined by the 80-μm scale of the microscope field of view, and we defined the area in the immediate vicinity of and that partially overlapped



with the photomask as Area 1 and the area further from the photomask as Area 2. The main observations in Area 1 (close to the photomask) are summarized in Fig. 2. The overall fluorescence image of Area 1 after completion of the photopolymerization is shown in Fig. 2a, with a blue

horizontal line indicating the edge of the mask. The numbers 1–6 denote examples of individual QDs that were tracked during the photopolymerization. The individual traces of the diffusing QDs are shown in Fig. 2b. More examples are shown in Fig. S4. The UV irradiation

was switched on 120 s before the start of the traces, i.e., at the value of '0' on the time scale in Fig. 2b, the irradiation had been on for 2 min. The traces were constructed from 600 consecutive fluorescence images taken every 0.1 s over the time span of 1 min. In each image, the position of the particular QD was determined as the centroid of a 2D Gaussian fit of the fluorescence spot.

QD 1 is located in the masked region where photopolymerization does not proceed during the experiment. This is reflected in the random Brownian motion of QD 1 throughout the measured time interval. To visualize the random nature of the diffusion, we analyzed the diffusion lengths of the QDs within individual intervals of 0.1 s. The lengths were analyzed separately in the directions parallel to the photomask edge (direction x) and perpendicular to it (direction y), as indicated in Fig. 2a. The results (plotted in Fig. 3a) confirm that the extent and direction of the diffusion in the masked region (in the molten state of the monomer) are completely random without any visible tendency.

Compared to the above results, QDs 2–6, which are located in the region where photoirradiation does occur during the measurement time, behave in a completely different way (Fig. 2b). In the early stages of the UV irradiation, they show random Brownian diffusion, similar to QD 1. As the polymerization reaction partially proceeds, the diffusion considerably slows down and becomes highly anisotropic. This trend is visualized by the plot of the diffusion lengths in the x and y directions of QD 2 in Fig. 3b. The scatter of the points during the first 30 s of the experiment resembles that of QD 1 (Fig. 3a). At 40–60 s, the magnitude of the diffusion lengths decreases, and the lengths in the y direction (perpendicular to the mask, blue dots) are significantly larger than those in the x direction (parallel to the mask, red dots). This reflects the directionality of the diffusion toward the photomask edge. Therefore, it is reasonable to assume that the polymerization had proceeded, causing directional diffusion of QD 2 in this time range.

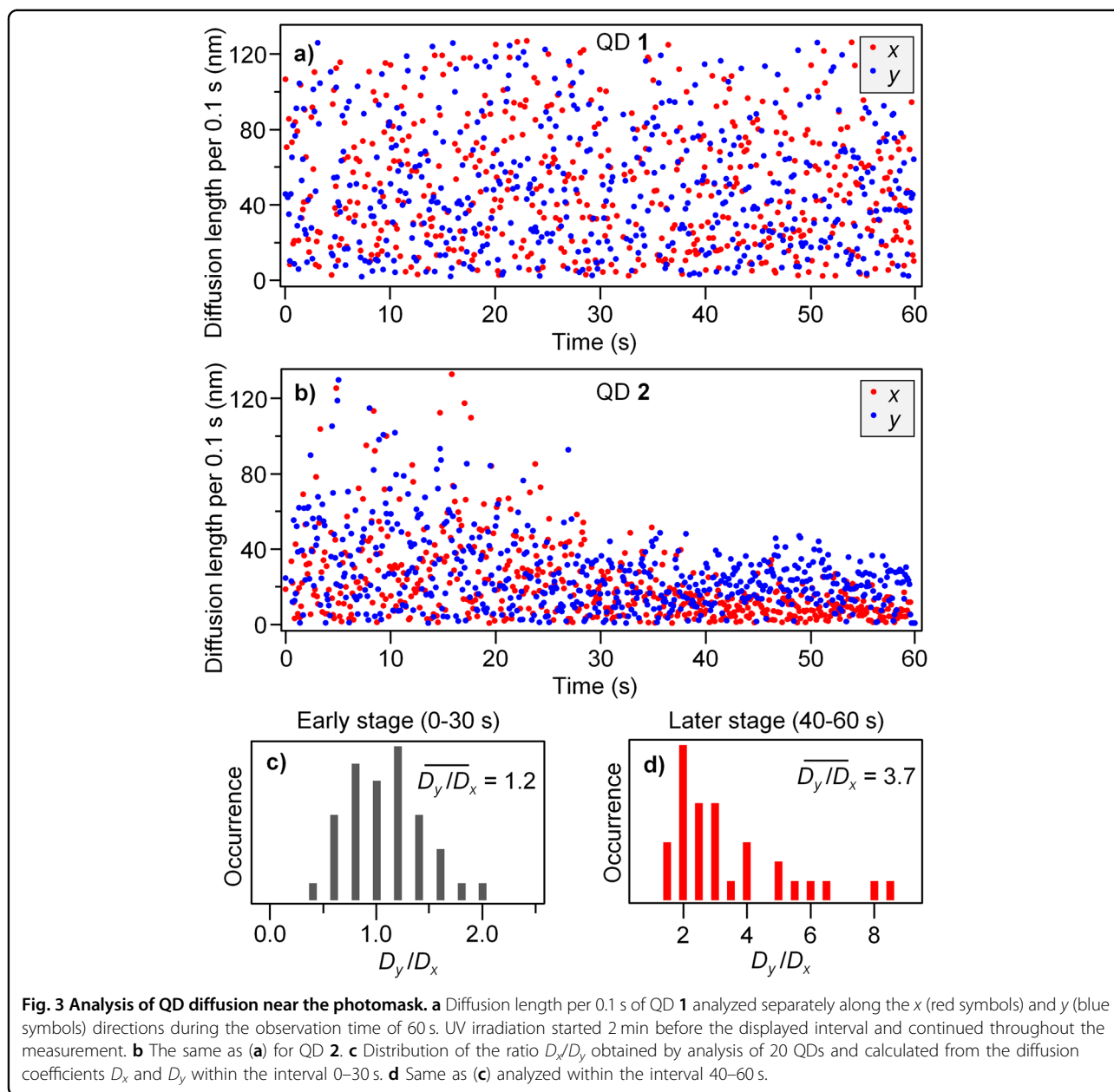
Interestingly, the observations in Fig. 2 also indicate that during the measurement window, the polymerization itself proceeds gradually, starting far from the photomask (at the bottom of the image) and approaching the photomask at the top of the image as time proceeds. This is reflected by the different patterns of the diffusion traces of the QDs. Those at the bottom (far from the photomask), such as QD 5 and QD 6, show mainly directional diffusion because at the start of the measurement window, they are in the region where polymerization has proceeded to some extent. In contrast, the traces closer to the photomask, such as QD 2 and QD 3, initially show random Brownian diffusion, which changes to directional flow as the polymerization proceeds further up (from the bottom of the image). More such examples are shown in Fig. S4,

where the trend is visible for QD A, QD B, and QD C in that order.

To quantify these observations, we further calculated diffusion coefficients D_x and D_y in the respective directions x and y using mean square displacement (MSD) analysis^{21,22}. The MSD values $\langle x_i^2(t/\tau) \rangle$ were typically constructed over the time t of 5 s from 50 data points of the diffusion lengths with intervals $\tau = 0.1$ s. The diffusion coefficients were determined from the MSD slope $\langle x_i^2(t/\tau) \rangle = 2Dt$. The diffusion coefficients calculated for statistical ensembles of the data are shown in the histograms in Fig. S5. Analysis of the random Brownian diffusion at different time points in the early stages of photopolymerization (such as 0–30 s in Fig. 3b) for 20 individual QDs provides a large distribution of the diffusion coefficients with an average D_x of $0.025 \mu\text{m}^2 \text{s}^{-1}$ and an average D_y of $0.027 \mu\text{m}^2 \text{s}^{-1}$ (Fig. S5a). Figure 3c shows the distribution of the ratio D_y/D_x for individual data points during the 0–30 s interval. The average of this ratio of 1.2 confirms the random nature of the diffusion. Analysis of the anisotropic directional diffusion of the 20 QDs observed in the later stages (such as 40–60 s in Fig. 3b) indicates an order of magnitude smaller average D_x of $0.0020 \mu\text{m}^2 \text{s}^{-1}$ and widely distributed D_y values with an average of $0.0054 \mu\text{m}^2 \text{s}^{-1}$ (Fig. S5b). The distribution of the ratio D_y/D_x during the 40–60 s interval shown in Fig. 3d has an average value of 3.7, confirming the directional nature of the diffusion toward the photomask edge.

To further verify the effect of the interface on the diffusion behavior of the QDs, we examined the photopolymerization process in Area 2 (as defined in Fig. 1c), the center of which is $\sim 100 \mu\text{m}$ from the photomask edge. Figure S6a shows an example of the diffusion traces of three QDs in a randomly selected section of Area 2. The range of diffusion is apparently smaller than that in Area 1 (Fig. 2). The diffusion of one of these QDs was visualized by plotting the diffusion length per 0.1 s in Fig. S6b. At < 10 s in Fig. S6b, this QD shows random Brownian diffusion, similar to QDs 1 and 2 in Fig. 3. In the later stage of photopolymerization, however, the diffusion completely stops in both the x and y directions, as reflected by the 0 values of the diffusion lengths. The same results were also obtained on control samples that were prepared without the use of a photomask (Fig. S7). In such samples, photopolymerization proceeded homogeneously throughout the sample, and anisotropic directional diffusion of QDs was not observed.

Based on the above observations, we have confirmed that the patterned photopolymerization causes diffusion of the QDs in a direction perpendicular to the boundary of the photomask and that this effect is observable within $< 70 \mu\text{m}$ from the mask edge. Further, we need to verify that in a sample prepared under the same conditions, the resulting LC polymer is actually aligned in one direction



in a narrow mesoscopic region near the photomask. For this purpose, we imaged such a sample using a polarized optical microscope, as shown in Fig. S8. The image clearly shows that LCs are aligned only in the illuminated region near the edge of the photomask.

A mechanism proposed earlier to account for the molecular alignment during photopolymerization assumed the formation of a chemical potential gradient between the unpolymerized masked region and the partially polymerized irradiated region at the interface¹². Under this concentration gradient, both monomers and polymers diffuse perpendicular to the mask edge in opposite directions. The anisotropic diffusion creates a thermodynamic force

that induces macroscopic mass flow in the direction perpendicular to the interface. This mass flow causes orientation of the polymer main chains and mesogenic side chains by shear stress, and the subsequent polymerization immobilizes their orientation. We believe that the directional diffusion of QDs from the partially polymerized region toward the photomask observed in this work directly reflects this proposed mass flow¹². Considering the chemical potential gradient, a mass flow from the polymerized region is directed into the area of unpolymerized monomers. The process of molecular alignment through mass flow is schematically shown in Fig. 4. Before photopolymerization, the QDs undergo free Brownian diffusion

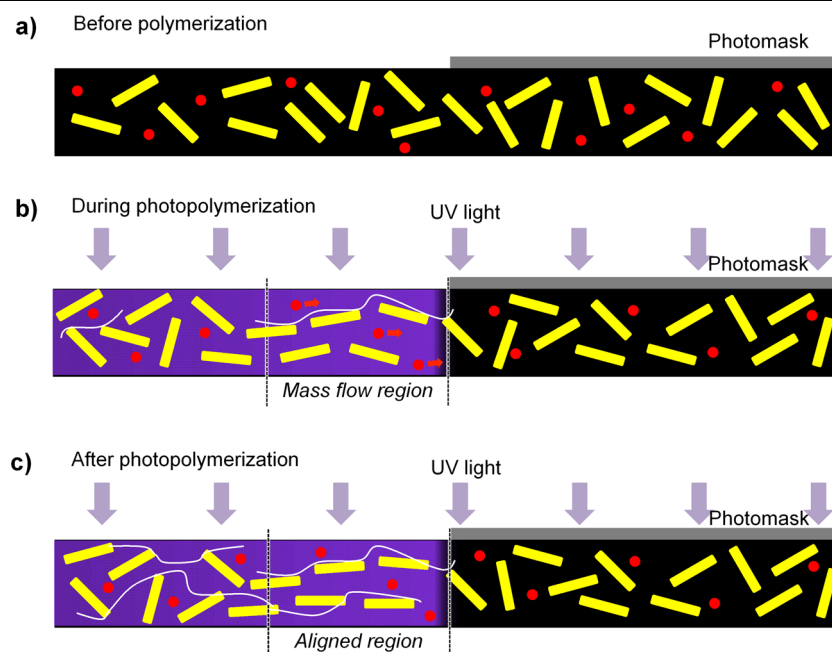


Fig. 4 Schematic illustration of the mechanism of molecular alignment during photopolymerization near a photomask. **a** Before photopolymerization; **b** during photopolymerization; **c** after photopolymerization. Yellow rods, red dots, and white lines indicate mesogenic side-chain units, quantum dots, and polymer main chains, respectively.

in the molten isotropic state, with relatively large diffusion constants (Fig. 4a). Upon UV irradiation, polymers are formed at a low concentration in the irradiated region (Fig. 4b). At the interface between the irradiated and unirradiated regions, the concentration gradient of the polymers forms a chemical potential, and the polymers diffuse into the masked region, producing mass flow. The QDs acting as a visualizer of the mass flow also diffuse directionally toward the mask edge. In the region distant from the photomask, the polymers effectively immobilize the QDs, as seen in Fig. S6b. Finally, continued irradiation completes the polymerization and fixes the alignment of the polymer main chain and mesogenic side chains perpendicular to the photomask (Fig. 4c). In principle, there should be mutual diffusion of the polymers and monomers in opposite directions. The directed motion of QDs toward the unirradiated region observed in this work indicates that the mass flow is dominated by polymer diffusion. Other mechanisms accounting for the motion of QDs might be possible. Lee et al. showed that QDs can reflect the mass flow of an unpolymerized LC in the nematic phase as well²², and Maeda et al. reported that competing mechanisms of diffusiophoresis and thermophoresis coexist in three-component systems^{23,24}. However, the directed motion of QDs observed in this work must be induced by diffusion of polymers, and the unidirectional diffusion of polymer chains resulted in molecular alignment during the patterned photopolymerization.

Conclusions

In conclusion, we used single-particle fluorescence imaging to reveal the molecular-level physical processes underlying the alignment of LCs during photopolymerization with structured light. We unambiguously showed that the photopolymerization is accompanied by macroscopic mass flow of side-chain LC polymers, which results in flow-induced orientation that is subsequently fixed by completion of the polymerization reaction. These results will not only have an impact in the field of polymer physics, where they will contribute to the knowledge on molecular alignment, but also be valuable for the further development of film orientation technology.

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Author details

¹Department of Materials Science and Engineering, Tokyo Institute of Technology, Ookayama 2-12-1-S8-44, Meguro-ku, Tokyo 152-8552, Japan.

²Laboratory for Chemistry and Life Science, Institute of Innovative Research, Tokyo Institute of Technology, R1-12, 4259 Nagatsuta, Midori-ku, Yokohama 226-8503, Japan. ³Present address: Research Institute for Sustainable Chemistry,

National Institute of Advanced Industrial Science and Technology, 1-1-1 Higashi, Tsukuba, Ibaraki 305-8565, Japan

Conflict of interest

The authors declare no competing interests.

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